

# Call for Papers



April 27-May 1

Spring  
92

San Francisco Marriott  
San Francisco, CA

**Abstract Deadline:**  
November 15, 1991

## SYMPOSIA

### **A: AMORPHOUS SILICON TECHNOLOGY - 1992**

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### **B: CHEMICAL SURFACE PREPARATION, PASSIVATION AND CLEANING FOR SEMICONDUCTOR GROWTH AND PROCESSING**

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### **C: ADVANCED METALLIZATION AND PROCESSING FOR SEMICONDUCTOR DEVICES AND CIRCUITS - II**

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### **D: PHOTO-INDUCED SPACE CHARGE EFFECTS IN SEMICONDUCTORS: PHOTOCONDUCTIVITY, SPECTROSCOPY AND ELECTRO-OPTICS**

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### **E: DEFECT ENGINEERING IN SEMICONDUCTOR GROWTH, PROCESSING AND DEVICE TECHNOLOGY**

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### **F: MECHANISMS OF HETEROEPITAXIAL GROWTH**

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### **G: ELECTRONIC PACKAGING MATERIALS SCIENCE VI**

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### **H: MATERIALS RELIABILITY**

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### **Ia: MATERIALS INTERACTIONS RELEVANT TO RECYCLING OF WOOD-BASED MATERIALS**

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**Ib: MATERIALS FOR ENERGY TECHNOLOGIES**

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**ic: MATERIALS FOR SEPARATION TECHNOLOGY**

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**J: MATERIALS ISSUES IN ART & ARCHAEOLOGY III**

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**K: MATERIALS MODIFICATION BY ENERGETIC ATOMS AND IONS**

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**L: MICROWAVE PROCESSING OF MATERIALS**

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**M: NOVEL FORMS OF CARBON**

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**N: BETTER CERAMICS THROUGH CHEMISTRY V**

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**O: CHEMICAL PROCESSES IN INORGANIC MATERIALS: METAL AND SEMICONDUCTOR CLUSTERS AND COLLOIDS**

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**P: AEROSOL PRECURSORS TO MATERIALS**

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**Q: INTERMETALLIC MATRIX COMPOSITES II**

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**R: SUBMICRON MULTIPHASE MATERIALS**

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**S: LAYERED SUPERCONDUCTORS: FABRICATION, PROPERTIES, AND APPLICATIONS**

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**T: DEFECT STRUCTURES IN CRYSTALLINE ELECTRONIC OXIDES**

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**V: MACROMOLECULAR HOST-GUEST COMPLEXES: OPTICAL AND OPTOELECTRONIC PROPERTIES AND APPLICATIONS**

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**W: COMPUTATIONAL METHODS IN MATERIALS SCIENCE**

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**X: FRONTIERS OF MATERIALS RESEARCH**

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**Y: MATERIALS FOR MICRO-ELECTRO-MECHANICAL SYSTEMS**

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